

# INVENTOR INFORMATION

Inventor One Given Name:: Koichiro  
Family Name:: TANAKA  
Postal Address Line One:: c/oSemiconductor Energy Laboratory Co.,Ltd  
Postal Address Line Two:: 398, Hase,  
City:: Atsugi-shi  
State or Province:: Kanagawa-ken  
Country:: Japan  
Postal or Zip Code:: 243-0036  
Citizenship Country:: Japan

## CORRESPONDENCE INFORMATION

Correspondence Customer Number:: 22204  
Fax One:: (703) 883-0370  
Electronic Mail One:: pluther@nixonpeabody.com

## APPLICATION INFORMATION

Title Line One:: LASER ANNEALING METHOD AND SEMICONDUCTOR  
Title Line Two:: DEVICE FABRICATING METHOD  
Total Drawing Sheets:: 23  
Formal Drawings?:: Yes  
Application Type:: Utility  
Docket Number:: 740756-2409  
Secrecy Order in Parent Appl.?:: No

## REPRESENTATIVE INFORMATION

Representative Customer Number:: 22204  
Registration Number One:: 38285  
Registration Number Two:: 35483  
Registration Number Three:: 45285  
Registration Number Four:: 27997  
Registration Number Five:: 26477

## PRIOR FOREIGN APPLICATIONS

Foreign Application One:: 2000-399462  
Filing Date:: 12-27-2000  
Country:: Japan  
Priority Claimed:: Yes

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